Notice of References Cited

| Application/Control No. Applicant(s)/ Reexaminati SMITH ET A | | nt Under |
|--|----------|-------------|
| Examiner | Art Unit | |
| COLLEEN M. BAPHAEL | 1724 | Page 1 of 2 |

U.S. PATENT DOCUMENTS

| | U.S. PATENT DOCUMENTS | | | | | |
|---|-----------------------|--|-----------------|----------------------|----------------|--|
| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Name | Classification | |
| * | Α | US-4,772,775 A | 09-1988 | Leach, Sam L. | 219/121,36 | |
| * | В | US-5,866,753 A | 02-1999 | Deam et al. | 204/157.15 | |
| * | С | US-6,038,853 A | 03-2000 | Penetrante et al. | 422/186.03 | |
| * | D | US-6,139,694 A | 10-2000 | Rogers et al. | 204/177 | |
| * | Е | US-2002/0012618 A1 | 01-2002 | Bromberg et al. | 422/190 | |
| * | F | US-6,395,144 B1 | 05-2002 | Yi et al. | 204/164 | |
| * | G | US-6,517,794 B2 | 02-2003 | Gieshoff et al. | 204/157.3 | |
| * | Н | US-6,620,394 B2 | 09-2003 | Uhm et al. | 423/240R | |
| * | - | US-6,635,228 B1 | 10-2003 | Moore et al. | 422/186.04 | |
| * | J | US-6,696,662 B2 | 02-2004 | Jewett et al. | 204/298.38 | |
| * | К | US-6,888,040 B1 | 05-2005 | Shufflebotham et al. | 95/116 | |
| * | L | US-6,962,679 B2 | 11-2005 | Josephson et al. | 423/241 | |
| * | М | US-7,220,396 B2 | 05-2007 | Aardahl et al. | 423/240R | |

FOREIGN PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Country | Name | Classification |
|---|---|--|-----------------|---------|------|----------------|
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NON-PATENT DOCUMENTS

| * | | Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages) | | | | |
|---|---|--|--|--|--|--|
| | U | Radoiu, "Studies of 2.45 GHz Microwave Induced Plasma Abatement of CF4," Environ. Sci. Technol. 2003, 37, pp. 3985-3988 | | | | |
| | v | Xu et al, "Plasma abatement of perfluorocompounds in inductively couple plasma reactors," J. Vac. Sci. Technol. A 18(1), Jan/Feb 2000, pp.213-231 | | | | |
| | w | Tonnis et al, "Inductively coupled, point-of-use plasma abatement of perfluorinated compounds and hydrofluorinated compounds from etch processes utilizing O2 and H2O as additive gases," J. Vac. Sci. Technol. A 18(2), Mar/Apr 2000, pp. 393-400 | | | | |
| | x | Vitale et al, "Abatement of C2F6 in RF and microwave plasma reactors," J. Vac. Sci. Technol. A 18(5), Sept./Oct. 2000, pp. 2217-2223 | | | | |

"A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

| Notice (| of Reference | s Cited |
|----------|--------------|---------|
|----------|--------------|---------|

| Ī | Application/Control No. | Applicant(s)/Pater | nt Under |
|---|-------------------------|-------------------------------|-------------|
| | 10/589,994 | Reexamination SMITH ET AL. | |
| | Examiner | Art Unit | |
| | COLLEEN M. RAPHAEL | 1724 | Page 2 of 2 |

ILS PATENT DOCUMENTS

| | | | | U.S. PATENT DOCUMENTS | |
|---|---|--|-----------------|-----------------------|----------------|
| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Name | Classification |
| | Α | US- | | | |
| | В | US- | | | |
| | С | US- | | | |
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| | J | US- | | | |
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| | L | US- | | | |
| | м | US- | | | |

FOREIGN PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Country | Name | Classification |
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| | Q | | | | | |
| | R | | | | | |
| | s | | | | | |
| | т | | | | | |

NON-PATENT DOCUMENTS

| * | | Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages) |
|---|---|---|
| | U | Radoiu, "Studies on atmospheric plasma abatement of PFCs," Radiation Physics and Chemistry 69 (2004), pp. 113-120 |
| | v | Hartz et al, "Innovative Surface Wave Plasma Reactor Technique for PFC Abatement," Environ. Sci. Technol. 1998, 32, pp. 682-687 |
| | w | |
| | х | |

A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.